PTO/SB/30 (08-00)

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## **CONTINUED EXAMINATION (RCE) TRANSMITTAL**

Subsection (b) of 35 U.S.C. § 132, effective on May 29, 2000, provides for continued examination of an utility or plant application filed on or after June 8, 1995. See The American Inventors Protection Act of 1999 (AIPA).

collection of information unless it displays a valid OMB control number.					
Application Number	09/662,358				
Filing Date	09/15/2000				
First Named Inventor	Taiji NODA et al.				
Group Art Unit	2814				
Examiner Name	A.D. Mai				
Attorney Docket Number	740819-423				

This is a Request for Continued Examination (RCE) under 37 C.F.R. § 1.114 of the above-identified application. NOTE: 37 C.F.R. § 1.114 is effective on May 29, 2000. If the above-identified application was filed prior to May 29, 2000, applicant may wish to consider filing a continued prosecution application (CPA) under 37 C.F.R. § 1.53(d) (PTO/SB/29) instead of a RCE to be eligible for the patent term adjustment provisions of the AIPA. See Changes to Application Examination and Provisional Application Practice, Final Rule, 65 Fed. Reg. 50092 (Aug. 16, 2000); Interim Rule, 65 Fed. Reg. 14865 (Mar. 20, 2000), 1233 Off. Gaz. Pat. Office 47 (Apr. 11, 2000), which established RCE practice.

1.	Submission required under 37 C.F.R. § 1.114											
	a.		Previ	ously submitted	CHI:DTC							
		i.		Consider the amendment(s)/reply under 37 C.F.R. § 1.116 (Any unentered amendment(s) referred to above will be entered).	previously filed on	TE 13 2993						
		ii.		Consider the arguments in the Appeal Brief or Reply Brie	f previously filed on							
		iii.		Other								
	b.	×	Enclo	sed	d The Cal							
		i.	×	Preliminary Amendment		228						
		ii.		Affidavit(s)/Declaration(s)		8						
		iii.	×	Information Disclosure Statement (IDS), Form PTO-1449	and Two Cited References	ţ.,						
		iv.		Other								
2.	Ν	⁄liscel	laneou	<u>.                                    </u>								
	a.		Susp	nsion of action on the above-identified application is requ months. (Period of suspension shall not exceed 3 mont								
	b.		Othe		,	•						
3.	E	ees	_	RCE fee under 37 C.F.R. § 1.17(e) is required by 37 C.F.R. § 1.11	when the RCE is filed.							
٠.	a.	X	⊒ The l	Director is hereby authorized to charge the following fees, o	or credit any overpayments, to I	Deposit Account No. 19-						
				740819-423)		_						
		i.		RCE fee required under 37 C.F.R. § 1.17(e)	02/12/2003 BABRAHA1 000	00086 09662358						
		ii.		Extension of time fee (37 C.F.R. §§ 1.136 and 1.17)	01 FC:1801	750.00 OP						
		iii.		Other	v. 10.1001							
	b.	×	Chec	in the amount of \$750.00 enclosed								
	C.		Payn	ent by credit card (Form PTO-2038 enclosed)								
				SIGNATURE OF APPLICANT, ATTORNE	, OR AGENT REQUIRED							
Name (Print/Type)			t/Type	Donald R. Studebaker Registra	ation No. (Attorney/Agent)	32,815						
Signature			Dull. 2 Date	February 11, 2003								
CERTIFICATE OF MAILING OR TRANSMISSION												
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Signature			Date									

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Docket No. 740819-423

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re F	Patent Application of	)		CEI CEI
Taiji NODA et al.			Group Art Unit: 2814	3 200 3 100 3 100 VEL
Serial No. 09/662,358			Examiner: Anh D. Mai	ENTER CLUTER
Filed:	September 15, 2000	)		280
For:	SEMICONDUCTOR DEVI METHOD FOR FABRICA' THE SAME	·		

## PRELIMINARY AMENDMENT

Commissioner for Patents Washington, D.C. 20231

Sir:

In response to the Examiner's final Office Action mailed November 18, 2002, please consider the following amendments and remarks in connection with the above-identified application.

## IN THE CLAIMS:

Please cancel claim 11 without prejudice or disclaimer to the subject matter disclosed therein.

Please amend the claim 6 as follows:

6. (Twice Amended) A method for fabricating a semiconductor device that includes an extended high-concentration dopant diffused layer of a first conductivity and a pocket dopant diffused layer of a second conductivity, comprising:

a first step of forming a gate electrode over a semiconductor region with a gate insulating film interposed therebetween;